SPECIFICATION AMENDMENTS

Page 7, kindly amend the paragraph from lines 2-4 as follows:

Figure 3 a schematic layout Figs. 3A and 3B are schematic layouts of a second transmission diffraction grating configuration on two masks which can be used in a double exposure process;

Page 7, kindly amend the paragraph from lines 6-8 as follows:

Figure 4 a schematic layout Figs. 4A and 4B are schematic layouts of a third transmission diffraction grating configuration on two masks which can be used in a double exposure process;

Page 7, kindly amend the paragraph from lines 10-11 as follows:

Figure 5 a schematic layout Figs. 5A and 5B are schematic layouts of a fourth transmission diffraction grating configuration; and